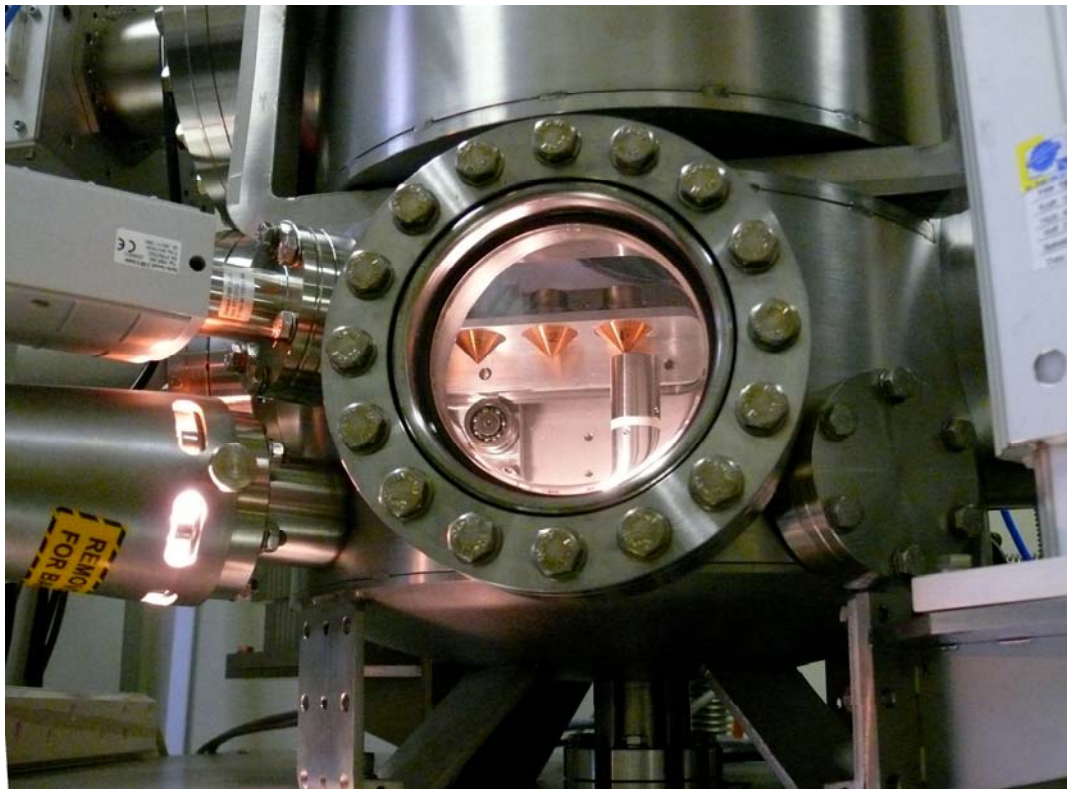


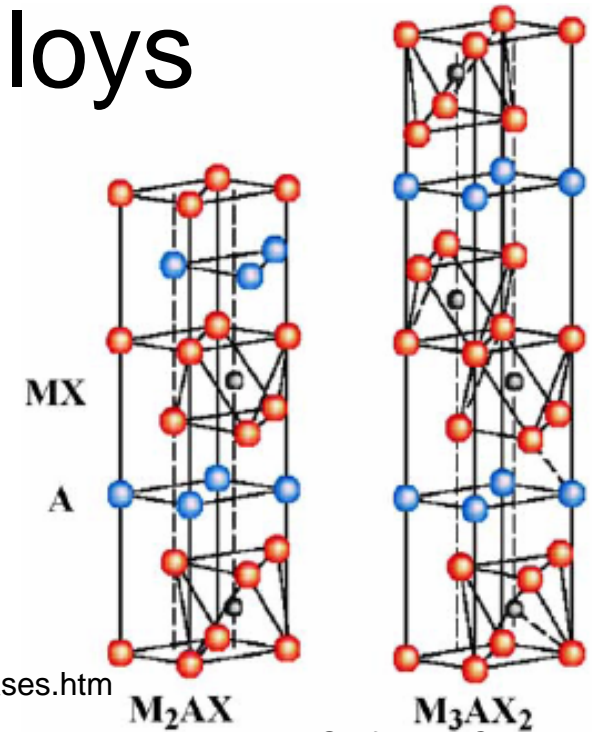
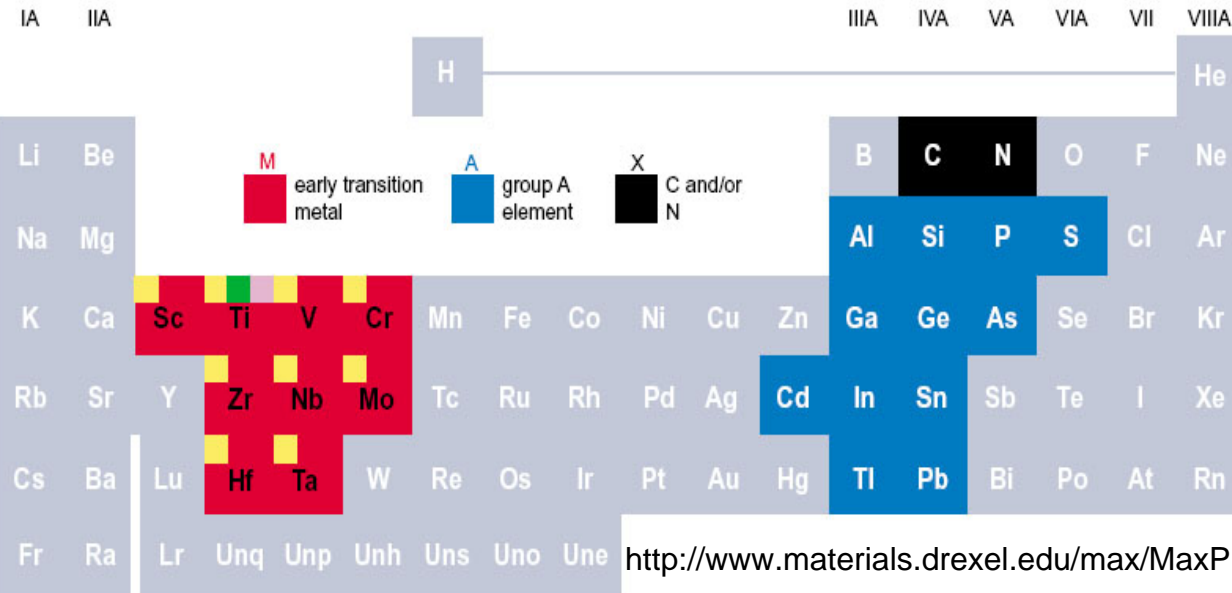
Synthesis and compositional analysis of thin film $M_{n+1}AX_n$ phases

M. Guenette, M. Tucker, Y. Yin, M.M.M. Bilek, D.R. McKenzie

School Of Physics, University Of Sydney



$M_{n+1}AX_n$ Phase Alloys



H. Högberg et al. *Surface & Coatings Technology* 193: 6–10, 2005

MAX phases exhibit a unique combination of ceramic and metallic properties

Ceramic

- Stiff
- Oxidation resistant
- High temperature stability

Metallic

- Machinable
- Resistant to thermal shock
- High thermal and electrical conductivity

Methods of Synthesis

Hot sintering^[1]

- Powders pressed into bulk form at high temperature ($>1500^{\circ}\text{C}$) and pressure ($\sim 50\text{MPa}$)
- Contains high levels of impurities and low phase purity, polycrystalline

DC magnetron sputtering^[2]

- Compound or multiple targets to synthesise single crystal thin films
- Substrate temperature $\sim 900^{\circ}\text{C}$

Pulsed Cathodic Arc^[3]

- Multiple cathode to synthesise single crystal thin films
- Substrate temperature $\sim 900^{\circ}\text{C}$

[1] Barsoum, M. et al, Journal of the American Ceramic Society , 82: 2545 1999

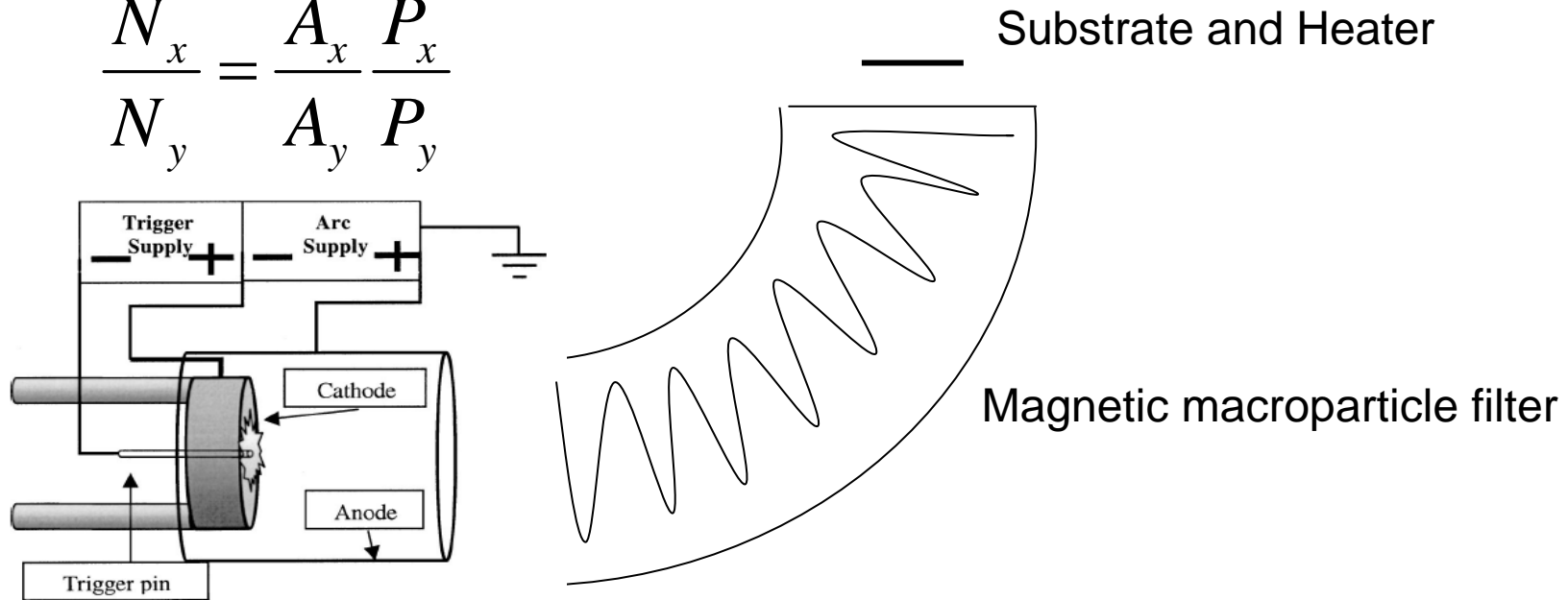
[2] Palmquist, JP. et al, Applied Physics Letters, 81 (5): 835-837 2002

[3] Rosen. J. et al, Journal of Applied Physics, 101 (5): 2007

Pulsed Cathodic Arc

- Stable, reproducible plasma density from 3 cathodes, M, A and X
- Can control number of plasma pulses from each elemental cathode and control amount of each element reaching the substrate
- Linear relationship between the number of pulses, P_x and amount of element reaching the substrate, N_x is expected.

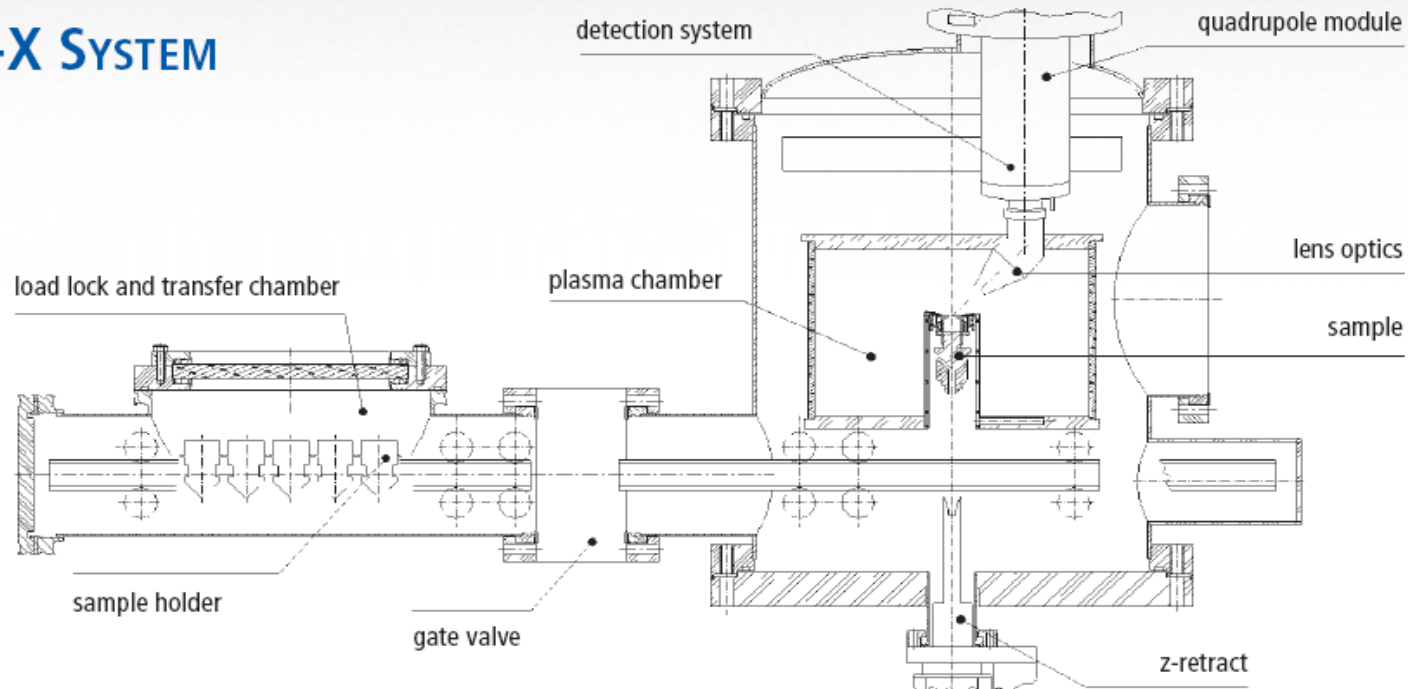
$$\frac{N_x}{N_y} = \frac{A_x P_x}{A_y P_y}$$



Cathode/Anode assembly x 3

Secondary Neutral Mass Spectrometry

THE INA-X SYSTEM

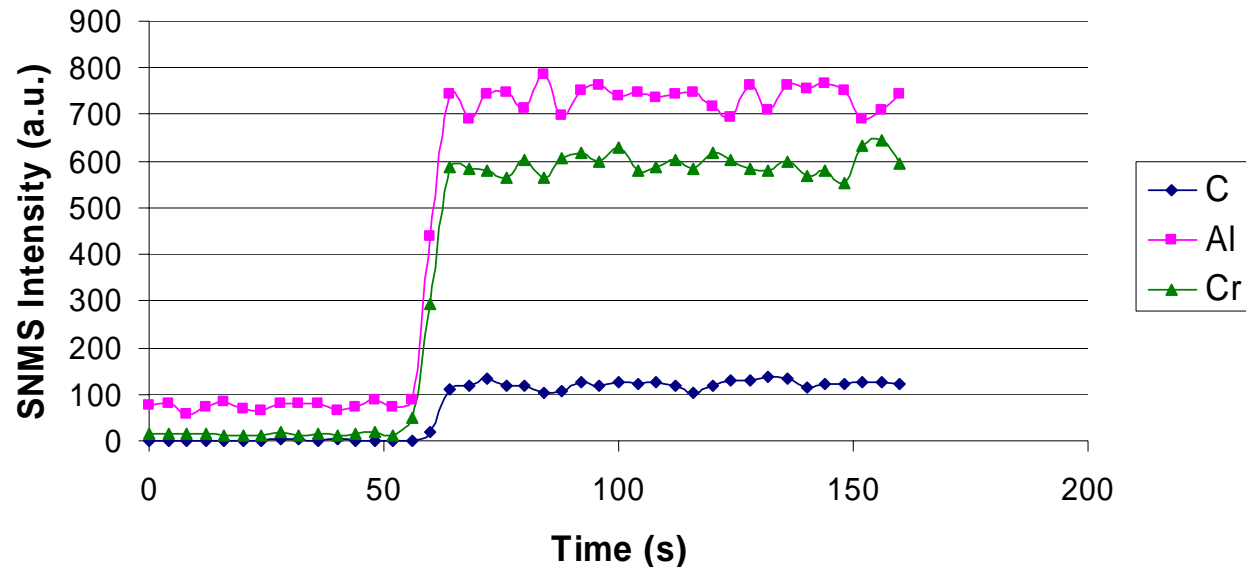


- Sample sputtered with Ar Plasma
- Emerging neutral particles are post-ionised and measured with mass spectrometer

SNMS Analysis

SNMS Time profile for Cr-Al-C sample

The elemental concentration ratio, C_x/C_y in the sputtered sample is directly proportional to the ratio of the SNMS signal intensity, I_x/I_y



$$\frac{C_x}{C_y} = \frac{I_x}{I_y} \frac{D_x}{D_y}$$

D_x/D_y are relative sensitivity factors that consider geometry, detection and ionisation probability.

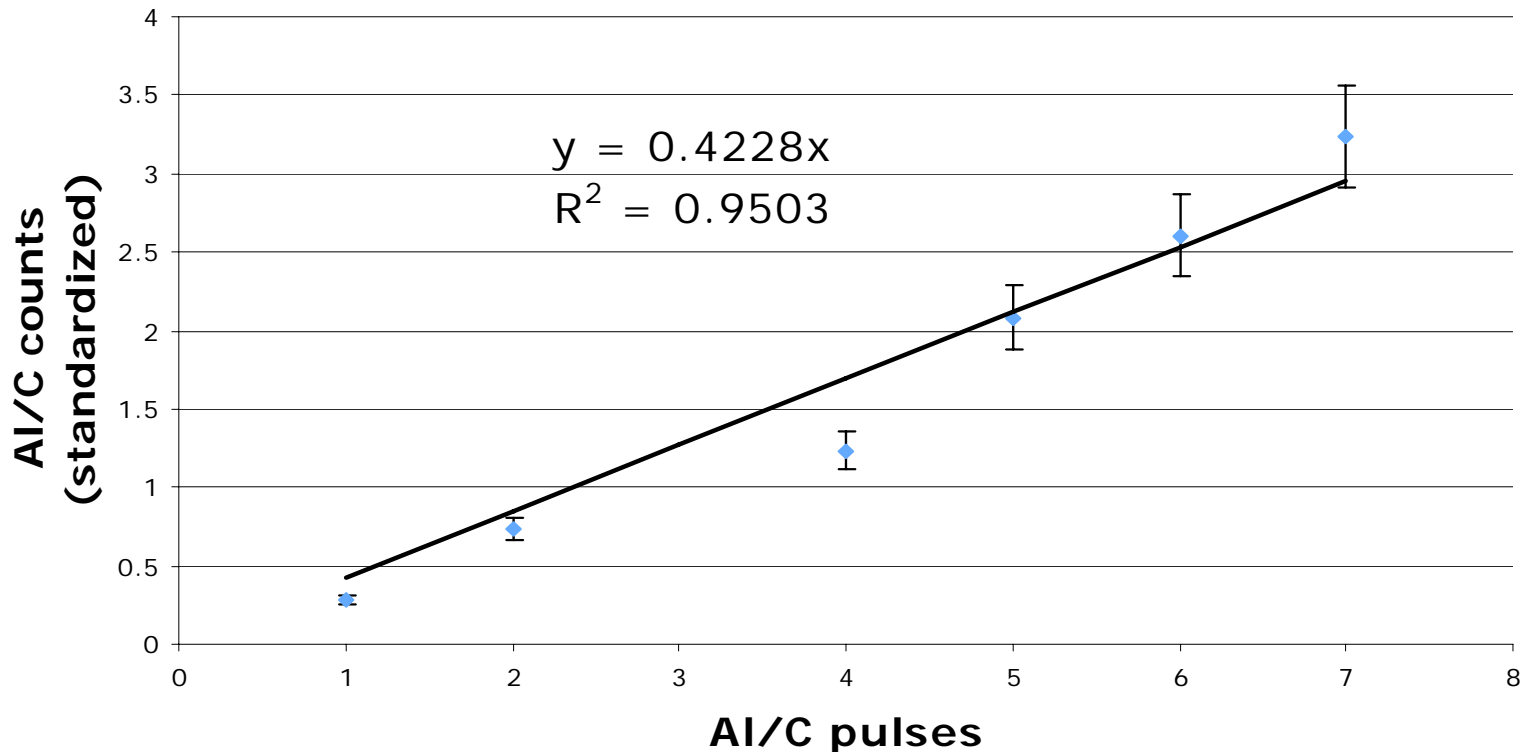
Quantitative composition analysis is possible with standards of known composition

SNMS and Pulsed Cathodic Arc

Combining the theory of SNMS and Pulsed cathodic arc, a linear relationship between pulse ratio and SNMS intensity ratio is expected.

$$\frac{P_x}{P_y} = M_{xy} \frac{I_x}{I_y}$$

Pulse ratio Vs SNMS intensity ratio for pulsed cathodic arc thin films



Summary

- Using the pulsed cathodic arc combined with SNMS composition analysis, a relationship between pulse ratio and stoichiometric ratio has been established given a set of constant deposition parameters.
- SNMS is a fast and reliable method of accurately controlling and quantifying the composition of thin film MAX phases

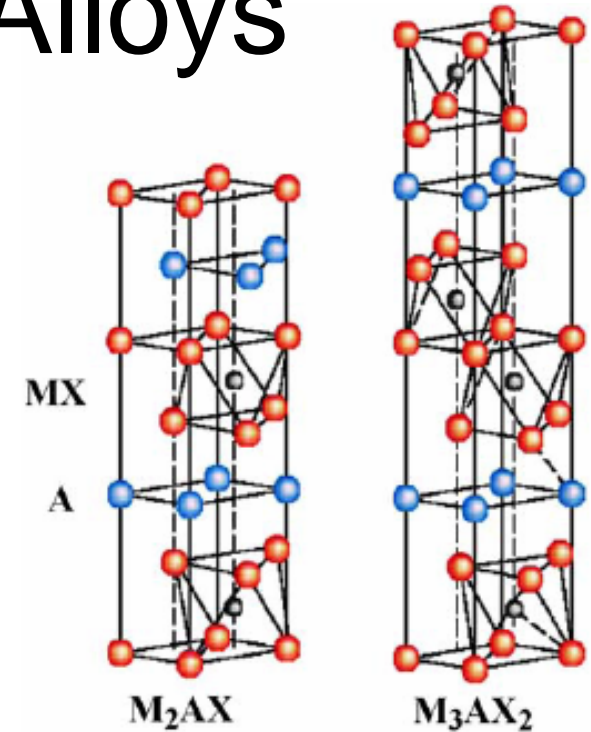




Mn+1AX_n Phase Alloys

IA	IIA											IIIA	IVA	VA	VIA	VII	VIIIA
																	He
Li	Be											B	C	N	O	F	Ne
Na	Mg											Al	Si	P	S	Cl	Ar
K	Ca	Sc	Ti	V	Cr	Mn	Fe	Co	Ni	Cu	Zn	Ga	Ge	As	Se	Br	Kr
Rb	Sr	Y	Zr	Nb	Mo	Tc	Ru	Rh	Pd	Ag	Cd	In	Sn	Sb	Te	I	Xe
Cs	Ba	Lu	Hf	Ta	W	Re	Os	Ir	Pt	Au	Hg	Tl	Pb	Bi	Po	At	Rn
Fr	Ra	Lr	Unq	Unp	Unh	Uns	Uno	Une									

■ M early transition metal
■ A group A element
■ X C and/or N



H. Högberg et al. *Surface & Coatings Technology* 193: 6–10, 2005

Ceramic

- Stiff, oxidation resistant, retains properties at high temperatures

Metallic

- Machinable, resistant to thermal shock, high thermal and electrical conductivity

Barsoum, M. W. *Progress in Solid State Chemistry*, 28(1-4): 201:281, 2000

<http://www.materials.drexel.edu/max/MaxPhases.htm>